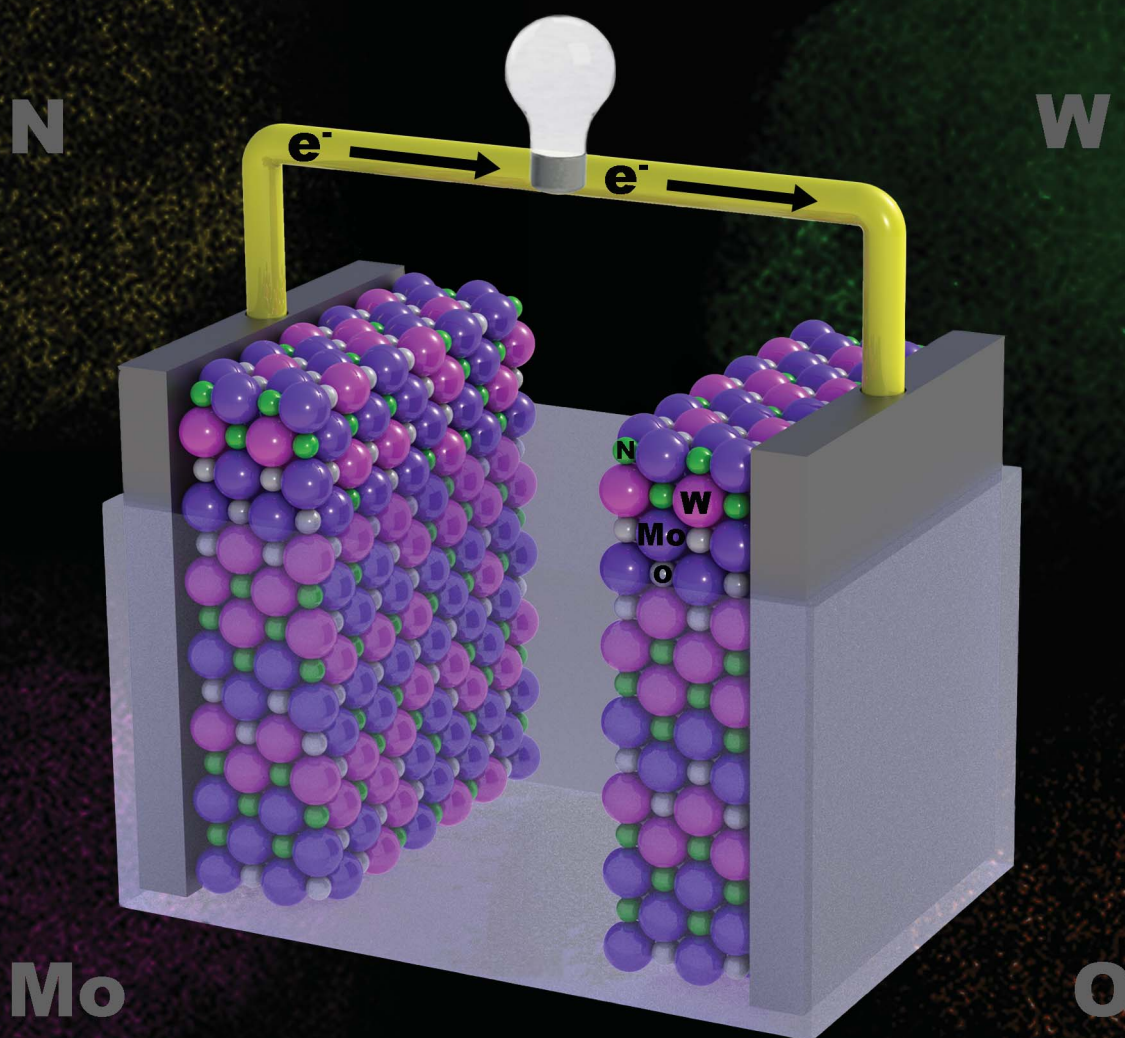


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Bimetallic molybdenum tungsten oxynitride: structure and electrochemical properties

Bimetallic molybdenum tungsten oxynitride: structure and electrochemical properties

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Mesoporous molybdenum tungsten oxynitride was synthesised by the temperature-programmed reduction of the bimetallic oxide precursor in ammonia and its electrochemical properties were investigated in 1 M H₂SO₄ aqueous electrolyte. The reaction product is a single-phase material, in which molybdenum and tungsten are distributed throughout the sample, with mesoporous morphology. The maximum of the pore size distribution is located at approximately 4 nm. Nearly rectangular voltammograms with the presence of small redox peaks were detected by cyclic voltammetry measurements in the acidic aqueous electrolyte, indicating properties relevant to electrochemical supercapacitors. The capacitance of 124 F g⁻¹ was measured by galvanostatic charge–discharge and 43% of the initial capacitance can be retained upon the 400-fold increase in the current density from 0.05 to 20 A g⁻¹. The electrochemical properties and the rate capability of the synthesised material are compared with those of monometallic oxynitrides of molybdenum and tungsten. A symmetric cell assembled with molybdenum tungsten oxynitride electrodes is also evaluated.

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Introduction

Transition metal nitrides and oxynitrides possess a unique set of physico-chemical characteristics including high conductivity, resistance to corrosion and catalytic activity.¹ In recent years, these nitrides and oxynitrides have been actively studied as electrode materials for various energy conversion and storage devices including dye-sensitised solar cells (DSSCs),^{2–4} metal-air batteries,^{5,6} lithium-ion batteries^{7–13} and supercapacitors.^{14–28} More specifically, the electrocatalytic activity of transition metal nitrides such as TiN⁵ or MoN⁶ has made them promising candidates for replacing noble metals catalysts for the oxygen reduction reaction. Additionally, the Pt-like electrocatalytic activity of transition metal nitrides enables their application in the counter electrodes of dye-sensitised solar cells, as an alternative to the expensive Pt for the reduction of triiodide ions in the electrolyte.^{2–4} Studies have confirmed that DSSCs with counter electrodes consisting of Mo₂N, W₂N or VN have reached 91%, 83% and 92%, respectively, of the photovoltaic performance of the DSSCs using Pt as a counter electrode.^{2–4} Furthermore, transition metal nitrides have been successfully applied in electrochemical energy storage devices. For example, vanadium nitride and chromium nitride thin films used as

anode materials in lithium ion batteries have reached reversible capacity values of approximately 800 mA h g⁻¹ for VN⁷ and 1200 mA h g⁻¹ for CrN⁸ through a conversion reaction mechanism, while Co₃N and Fe₃N thin films attained reversible capacity values fluctuating between 324 and 420 mA h g⁻¹ for Co₃N and between 323 and 440 mA h g⁻¹ for Fe₃N, respectively.⁹ Furthermore, bulk CrN nanoparticles have demonstrated a reversible capacity of approximately 500 mA h g⁻¹,¹⁰ while bulk CoN nanoparticles and CoN nanoflake films have reached a reversibly capacity of 660 mA h g⁻¹ and 990 mA h g⁻¹, respectively.^{11,12} Additionally, a reversible capacity of 400 mA h g⁻¹ has been reported for (Ni_{0.33}Co_{0.67})N nanoparticles.¹³

Among applications in energy conversion and storage devices, the use of transition metal nitrides and oxynitrides in supercapacitor electrodes has been promising due to their high intrinsic conductivity and their resistance to corrosion.¹⁴ Nitrides and oxynitrides of vanadium,^{14–18} tungsten,^{19–21} molybdenum^{22–24,27} and titanium^{25,26,28} have demonstrated pseudocapacitive behaviour, with typical capacitance values between 30 and 350 F g⁻¹ in aqueous electrolytes. Rate capability of the active materials is an important performance criterion, as supercapacitors used in the high power applications such as the automotive sector, smart grids or power backup systems are required to deliver energy in the pulse form and work at high discharge currents.^{29,30} Unlike many transition metal oxides, nitrides and oxynitrides possess high conductivities and therefore good rate capabilities. For example, W_{0.75}(N,O) has demonstrated about 40% of the capacitance retention upon the increase of the current load from 0.05 to 10 A g⁻¹,²¹ while VN has

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shown 79% of its initial capacitance at 0.05 A g^{-1} , at a current load of 1 A g^{-1} .¹⁷ TiN–VN core–shell mesoporous fibres retained 64% of the initial capacitance after increasing the current from 2 to 10 A g^{-1} .²⁸

It has been previously observed that a partial substitution of one transition metal by another in the crystal lattice of nitrides or oxynitrides could alter their physico-chemical properties.^{31–33} For instance, bimetallic compounds such as cobalt molybdenum nitride³¹ or vanadium molybdenum oxynitride³³ have demonstrated superior catalytic properties when compared to the corresponding monometallic compounds. However, for supercapacitor electrode materials, studies have been almost exclusively focusing on the monometallic nitride compounds so far, and only limited information exists on the electrochemical performance of bimetallic transition metal nitrides and oxynitrides. Experimental data have been reported on the mixed $\gamma\text{-Mo}_2\text{N}$ and $\text{Co}_3\text{Mo}_3\text{N}$ “composite material” demonstrating higher capacitance values than those of the pure $\gamma\text{-Mo}_2\text{N}$ compound.²⁴ Meanwhile, the electrochemical performance of the pure bimetallic compound has not been studied. It is, in our view, interesting to study how the introduction of the second metal into the crystal lattice of nitrides and oxynitrides influences their electrochemical performance in supercapacitors.

In this article, a bimetallic molybdenum tungsten oxynitride is characterised as a supercapacitor electrode material. The oxynitride is synthesised by a temperature-programmed reduction (TPR) of the oxide precursor in NH_3 . The synthesised material is extensively characterised by X-ray diffraction (XRD), scanning electron microscopy (SEM), low temperature N_2 adsorption and transmission electron microscopy (TEM). Electrochemical properties of the material are studied in $1 \text{ M H}_2\text{SO}_4$ electrolyte by performing cyclic voltammetry and galvanostatic charge–discharge measurements in the three-electrode configuration as well as in the symmetric cell, emulating an accepted design of an electrochemical capacitor. Furthermore, samples are analysed by electrochemical impedance spectroscopy (EIS). The electrochemical performance of molybdenum tungsten oxynitride is compared to those of the monometallic molybdenum oxynitride and tungsten oxynitride synthesised from the oxides of the corresponding metals by a temperature-programmed reduction under similar experimental conditions.

Experimental

Synthesis

Molybdenum tungsten oxynitride was synthesised by a solid state route similar to the method described by C. C. Yu and S. T. Oyama.³² 13.5 g of WO_3 (Sigma-Aldrich, 95410) and MoO_3 (Sigma-Aldrich, 267856) mixture in a 1 : 1 ratio was placed inside a planetary ball mill (Fritsch Pulverisette 5) and milled for 50 hours in order to achieve a high homogeneity of the mixture. Steel balls with 20 mm diameter were used with the 1 : 20 powder to ball ratio and the rotor speed was set to 150 rpm. The milled powder was subsequently pressed into pellets with 13 mm diameter dye under the pressure load of 8 tonnes. The pellets were annealed in an alumina crucible inside a horizontal tube furnace with open ends of the tube (Tetlow

Kilns & Furnaces Pty Ltd, Australia) at $785 \text{ }^\circ\text{C}$ for 6 hours and naturally cooled down to room temperature. The annealed pellets were crushed into powder again with an agate mortar in order to proceed to the temperature-programmed reduction process. Temperature-programmed reduction of the mixed oxide powder was performed in the same tube furnace (Tetlow Kilns & Furnaces Pty Ltd, Australia) under ammonia flow. First, the furnace was heated to approximately $700 \text{ }^\circ\text{C}$ with the heating rate of $5 \text{ }^\circ\text{C min}^{-1}$, kept at that temperature for 3 hours and cooled down to room temperature naturally. The NH_3 flow was set to 0.4 l min^{-1} throughout the experiment. Finally, the sample was passivated with a special gas mixture (Ar with 0.1% O_2) for 1 hour at a flow rate of 0.5 l min^{-1} prior to the exposure to air. In order to compare the electrochemical performance of the bimetallic oxynitride to those of the monometallic compounds, tungsten and molybdenum oxynitrides were synthesised by the temperature-programmed reduction of the corresponding oxides. Synthesis details of the TPR for monometallic oxynitrides are described elsewhere.^{21,34–37} For simplicity, the synthesised materials are denoted as MoW(N,O), W(N,O) and Mo(N,O).

Characterisation

The morphology of the synthesised material was examined by scanning electron microscopy (SEM, Carl Zeiss SUPRA 55VP). Surface area and porosimetry measurements were performed using a Micromeritics Tristar 3000 analyser. From the low temperature N_2 adsorption isotherm, pore size distribution and surface area were calculated by Barrett–Joiner–Helenda (BJH) and Branauer–Emmett–Teller (BET) methods, respectively. A PANalytical X’Pert PRO diffractometer with Cu K-alpha radiation ($\lambda = 0.15418 \text{ nm}$) was used to measure the X-ray diffraction pattern of the material.

The transmission electron microscopy (TEM) examination was carried out in an FEI Titan instrument operating at 300 kV accelerating voltage. The TEM instrument is equipped with a scanning unit (STEM), a Gatan Imaging Filter (GIF), and an energy dispersive X-ray (EDX) spectrometer. For energy-filtered TEM (EFTEM) imaging, a three-window method was employed to acquire tungsten, nitrogen, and oxygen elemental distributions.

Electrochemical testing

For the electrochemical characterisation of the synthesised material, electrode slurry was prepared by mixing molybdenum tungsten oxynitride, carbon nanopowder (Sigma-Aldrich, #699632) and poly(vinylidene)fluoride (PVDF, Sigma-Aldrich) in a 90 : 5 : 5 ratio. NMP (*N*-methyl-2-pyrrolidone, anhydrous, 99.5%, Sigma-Aldrich) was used as a solvent. Electrode slurries were coated onto titanium foils and dried in a vacuum at $90 \text{ }^\circ\text{C}$ overnight in a conventional oven. The weight of the active material on the dried electrodes was between 2 and 4 mg cm^{-2} . Electrodes were assembled into three-electrode cells using a Pt wire as a counter electrode and Ag/AgCl as a reference electrode. Symmetric cells were prepared by immersing two nearly identical electrodes separated by a microporous polyethylene film (MTI Corp., USA) into the electrolyte. Cells were filled with 1 M



H_2SO_4 electrolyte under vacuum and characterised by galvanostatic charge–discharge as well as cyclic voltammetry measurements using a Solartron Analytical 1470E potentiostat/galvanostat. The impedance spectroscopy was performed in the symmetric cell configuration at the open circuit potential (OCP) from 50 kHz to 0.05 Hz using an Ivium-*n*-stat electrochemical analyser. The amplitude of the modulation signal was set to 10 mV. Experimental data were fitted with ZView software.

Results and discussion

Characterisation

The XRD pattern of the synthesised compound (Fig. 1) shows five diffraction peaks located at 37.4° , 43.3° , 63.0° , 75.9° and 80.0° , matching the diffraction lines of $\text{MoWN}_{2.1}\text{O}_{2.4}$ (Powder Diffraction File #: 50-0134). It is in agreement with the assumption that the dominant phase in the sample is molybdenum tungsten oxynitride with a cubic structure.³² The broadening of the diffraction peaks indicates a small crystalline size and a possible high surface area of molybdenum tungsten oxynitride, consistent with the previous reports.³² Indeed, the surface area of $72.6 \text{ m}^2 \text{ g}^{-1}$ is measured by the BET method.

Low temperature nitrogen adsorption–desorption isotherm (Fig. 2a) demonstrates a hysteresis and belongs to type IV, indicating that the material is mesoporous. BJH measurements show a narrow pore size distribution, with the maximum located at around 4 nm (Fig. 2b) and virtually no pores larger than 12 nm are present in the sample.

The low magnification SEM image (Fig. 3a) shows that particle sizes of the synthesised powder do not exceed $1 \mu\text{m}$, while the high resolution image (Fig. 3b) indicates that particles are porous, with the visible pore sizes less than 10 nm, consistent with the low temperature nitrogen adsorption measurements. In order to characterise the structure of molybdenum tungsten oxynitride in more detail, the synthesised material is investigated by TEM. A bright field TEM images confirms the nanocrystalline structure of the synthesised material (Fig. 3c and e). The electron diffraction pattern (Fig. 3d) shows five diffraction rings, in agreement with the XRD pattern (Fig. 1). EFTEM maps of W, Mo, N and O

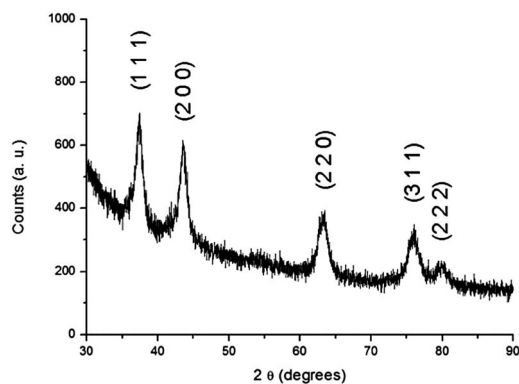


Fig. 1 XRD pattern of the synthesised material with the characteristic diffraction peaks of molybdenum tungsten oxynitride (Powder Diffraction File #: 50-0134).

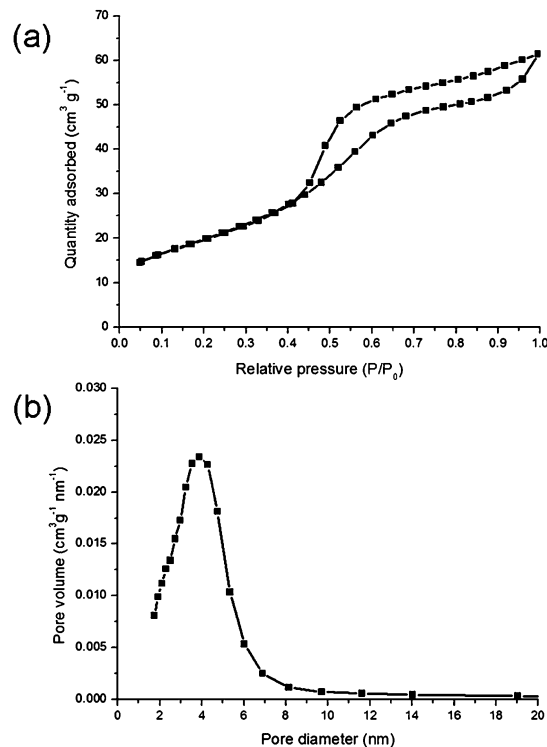


Fig. 2 Low temperature nitrogen adsorption measurements: adsorption–desorption isotherm (a) and the pore size distribution (b).

(Fig. 3f) taken from the area depicted in Fig. 3e show that the elements are distributed throughout the sample.

Electrochemical properties

It follows from the analysis of the selected specific capacitance values reported in the literature for the monometallic nitrides and oxynitrides^{14,19–23,27} of molybdenum and tungsten (Table 1) that the electrochemical properties of these phases vary considerably depending on the precursor and synthesis conditions.

For example, the capacitance of $\gamma\text{-Mo}_2\text{N}$ may vary in a wide range between 70 and 380 F g^{-1} .^{14,22,23,27} For consistency, here we compare the electrochemical properties of molybdenum tungsten oxynitride with those of molybdenum and tungsten oxynitrides synthesised from their corresponding oxide powders under similar nitridation conditions (TPR in ammonia with a maximum temperature of 700°C). The detailed characterisation of these $\text{Mo}(\text{N},\text{O})$ and $\text{W}(\text{N},\text{O})$ samples is presented elsewhere.³⁷

Cyclic voltammetry (CV) measurements in the three-electrode cell configuration (Fig. 4a) indicate that the operating potential window of molybdenum tungsten oxynitride is between -0.2 and $0.55 \text{ V vs. Ag/AgCl}$ in $1 \text{ M H}_2\text{SO}_4$ aqueous electrolyte. The CV curves have nearly rectangular shapes at various scan rates, with small reversible redox peaks present in cyclic voltammograms, typical for pseudocapacitive materials.

It could be observed that the operating potential window of the bimetallic oxynitride as well as the shape of the CV curves in $1 \text{ M H}_2\text{SO}_4$ electrolyte differ from both molybdenum and



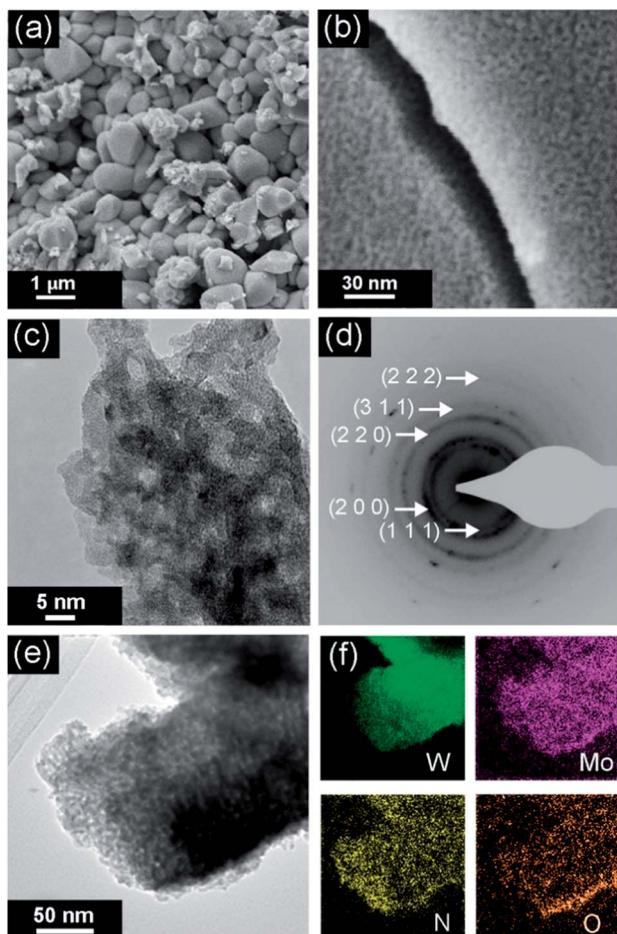


Fig. 3 Electron microscopy characterisation: SEM images (a and b); bright field TEM image and the electron diffraction pattern (c and d); a TEM image and the corresponding EFTM maps depicting the distribution of W, Mo, N and O elements (e and f).

tungsten monometallic compounds synthesised from the pure oxide precursors (Fig. 4b). In fact, tungsten oxynitride produced from the WO_3 precursor has an ideal rectangular CV curve in the voltage window between -0.4 and 0.5 V vs. Ag/AgCl with no visible redox peaks, while molybdenum oxynitride synthesised from the MoO_3 precursor operates between -0.5 and 0.5 V vs. Ag/AgCl and possesses several redox peaks as well as a less rectangular cyclic voltammogram (Fig. 4b).

The shape of the galvanostatic charge and discharge curves (Fig. 5a) is close to triangular. This shape is preserved when

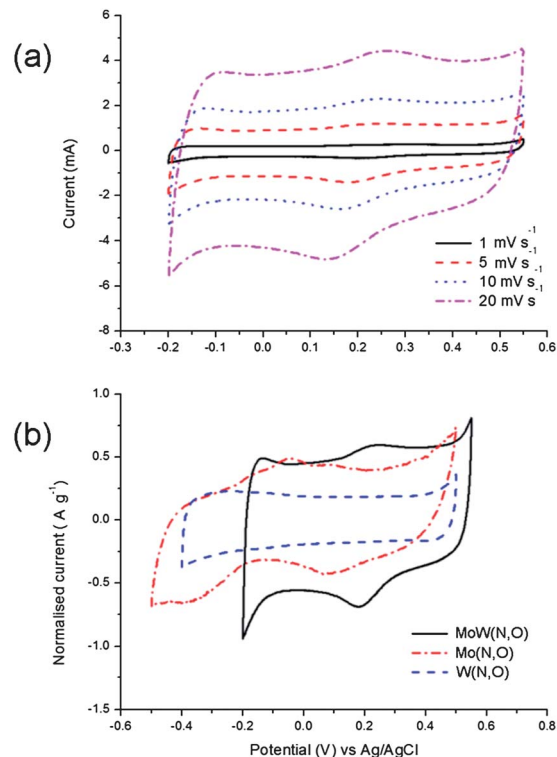


Fig. 4 Electrochemical characterisation of MoW(N,O) as a supercapacitor electrode material in 1 M H_2SO_4 electrolyte. Cyclic voltammograms (third cycle) at various scan rates (a) and CV of the bimetallic oxynitride compared to the cyclic voltammograms of the monometallic compounds at a scan rate of 5 mV s^{-1} ; the current is normalised with the weight of the active material (b).

increasing the current load from 0.5 to 10 A g^{-1} , although an IR drop is observed at high currents. 43% of the capacitance is retained upon increasing the current density from 0.05 to 20 A g^{-1} . The maximum reversible specific capacitance value measured at 0.05 A g^{-1} in 1 M H_2SO_4 electrolyte is 124 F g^{-1} ($172 \mu\text{F cm}^{-2}$). This value is orders of magnitude higher when compared to the typical $20\text{--}50 \mu\text{F cm}^{-2}$, characteristic of the electrical double layer charge storage mechanism,³⁸ indicating the presence of pseudocapacitive processes.³⁹ Cyclic stability measurements (Fig. 6) reveal that molybdenum tungsten oxynitride retains 46% of its initial capacitance after 5000 galvanostatic charge and discharge cycles at a current load of 5 A g^{-1} .

It can be noted that, at the same charge–discharge current densities, the bimetallic compound possesses higher specific capacitance values as well as a better rate capability when

Table 1 Selected specific capacitance values reported in the literature for the monometallic molybdenum and tungsten oxynitrides

	Surface area ($\text{m}^2 \text{ g}^{-1}$)	Precursor for TPR	Potential window (V)	Maximum specific capacitance	Ref.
$\gamma\text{-Mo}_2\text{N}$	152	$(\text{NH}_4)_6\text{Mo}_7\text{O}_{24} \cdot 4\text{H}_2\text{O}$	0.8 (H_2SO_4 0.1 M)	380 F g^{-1}	14
$\gamma\text{-Mo}_2\text{N}$	16	MoO_3	0.8 (H_2SO_4 3.5 M)	125 F g^{-1}	23
$\gamma\text{-Mo}_2\text{N}$	98	—	0.6 (H_2SO_4 4.5 M)	70 F g^{-1}	27
$\gamma\text{-Mo}_2\text{N}$	—	MoO_3	1.1 (H_2SO_4 1 M)	172 F g^{-1}	22
WN	46.7	Amorphous W-N	0.8 (KOH 1M)	30 F g^{-1}	19
W_2N	50.2	Layered $\text{WO}_3 \cdot \text{H}_2\text{O}$	0.8 (KOH 1M)	$\sim 100 \text{ F g}^{-1}$	20
$\text{W}_{0.75}(\text{N},\text{O})$	42	WO_3	0.8 (KOH 1 M)	57 F g^{-1}	21



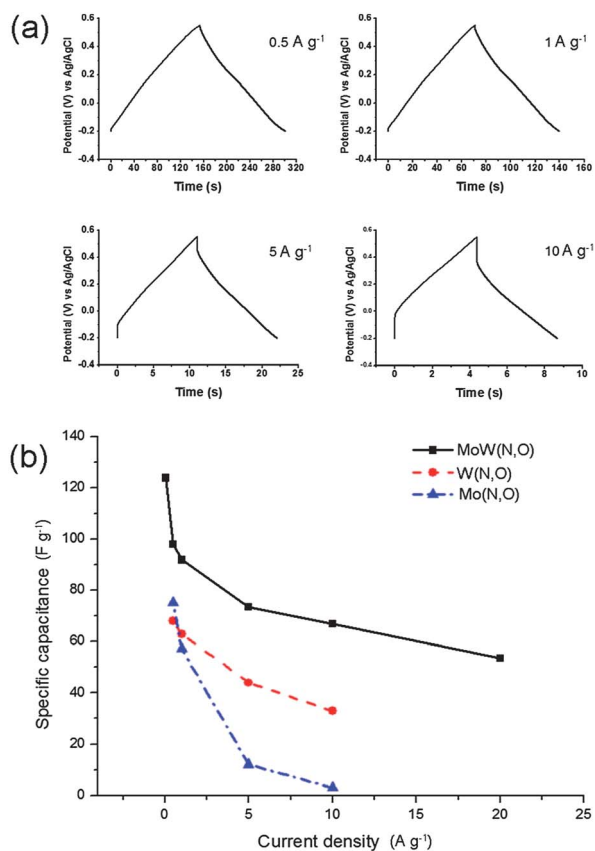


Fig. 5 Galvanostatic charge and discharge curves of molybdenum tungsten oxynitride (a) and its rate capability in 1 M H₂SO₄ electrolyte (b). Rate capabilities of molybdenum and tungsten oxynitrides are given for comparison in (b).

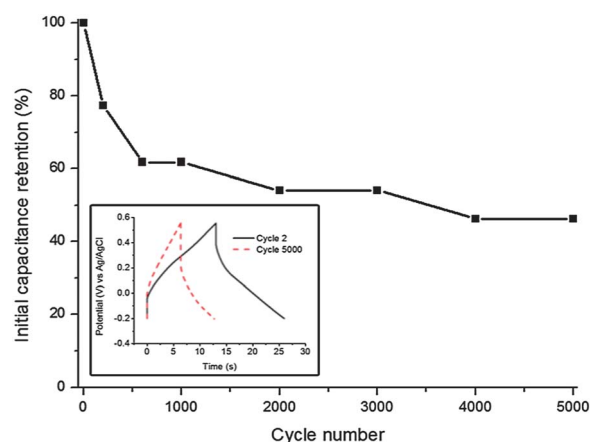


Fig. 6 Cyclic stability of molybdenum tungsten oxynitride in 1 M H₂SO₄ electrolyte cycled at a current load of 5 A g⁻¹: initial capacitance retention and galvanostatic charge and discharge curves (inset).

compared to both oxynitrides synthesised from MoO₃ or WO₃ (Fig. 5b). At a high current load of 10 A g⁻¹, MoW(O,N) possesses a specific capacitance of 67 F g⁻¹, twice the corresponding value for tungsten oxynitride,²¹ while the capacitance of molybdenum oxynitride quickly fades and reaches only 2 F g⁻¹ at a current density of 10 A g⁻¹. In order to investigate the

difference between the electrochemical performances of the samples further, the electrochemical impedance spectroscopy data were collected for molybdenum tungsten oxynitride electrodes and compared to the corresponding data measured for the monometallic compounds.

Nyquist plots of the impedance spectra are presented in Fig. 7a–c. A depressed semi-circle is observed at high frequencies, attributed to the charge transfer resistance and the double layer charging of the electrode surface, followed by an inclined straight line, characteristic of the Warburg region.^{40–43} In order to describe the impedance at high-medium frequencies, experimental data are fitted to a Randles-type equivalent circuit (Fig. 7d), where the double layer capacitance as well as the diffusion impedance within the pores of the electrode material are represented by constant phase elements (CPE).^{43–45} The proposed equivalent circuit fits the experimental data well in the high-frequency region (Fig. 7d).

The equivalent circuit contains the following variables: the bulk resistance (R_b), distributed double-layer capacitance within the pores (CPE_{dl}), charge transfer resistance (R_{ct}) and the diffusion impedance in the porous electrode (CPE_w). Equivalent circuit data are fitted with ZView software and are summarised in Table 2. The impedance of the CPE element is defined as:^{40,43}

$$Z_{CPE} = \frac{1}{Y_0(j\omega)^\alpha}, \quad (1)$$

where Y_0 is admittance, j is the imaginary unit, ω is the modulation frequency and α is a dimensionless coefficient. When $\alpha = 1$, the CPE behaves as an ideal capacitor while at

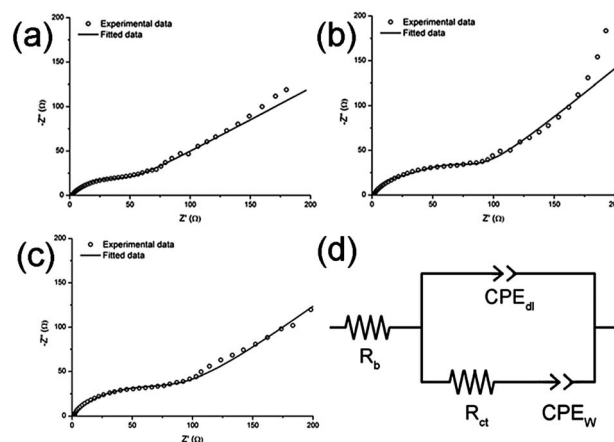


Fig. 7 Nyquist plots of the impedance spectra of molybdenum tungsten (a), tungsten (b) and molybdenum (c) oxynitrides and the equivalent circuit used to fit the experimental data (d).

Table 2 Fitted impedance data modelled with a Randles-type equivalent circuit (Fig. 7d)

	R_b (Ω)	R_{ct} (Ω)	R_w (Ω)/ α (–)	C_{dl} (F)/ α (–)
MoW(N,O)	1.6	60.5	111/0.46	0.00059/0.61
Mo(N,O)	1.0	90.8	141/0.50	0.00039/0.68
W(N,O)	1.2	101.3	118/0.58	0.00056/0.66



$\alpha = 0.5 Z_{\text{CPE}}$ demonstrates the transmission line behaviour and represents the mass transport impedance within the pores, with a characteristic 45° phase angle.^{40,43–45}

The charge transfer resistance R_{ct} represents the charge transfer resistance at the electrode–electrolyte interface. More specifically, the charge transfer reaction is often determined by the rate of electron transfer towards the interface, and is associated with intrinsic properties of the active electrode material such as the electronic conductivity, since electrons are the reactants in the charge transfer process.^{40–43} The lowest value of R_{ct} for molybdenum tungsten oxynitride electrodes could be attributed to their superior electronic conductivity in respect to those of both monometallic compounds.

Symmetric cell

The assembled supercapacitor devices could be classified into several categories according to the cell design and active materials used.^{30,46,47} In this work, two molybdenum tungsten oxynitride electrodes were tested in the symmetric configuration as an approximation of a real device.

The cyclic voltammetry curve demonstrates an ideal rectangular shape in the potential range between 0 and 0.75 V in 1 M H_2SO_4 electrolyte at the scan rates of 1, 5, 10 and 20 mV s^{-1} (Fig. 8a). Interestingly, no redox peaks can be observed in the cyclic voltammograms of the symmetric device. Galvanostatic charge and discharge curves form nearly ideal triangular shapes (Fig. 8b) at the current densities of 0.5, 1, 5, and 10 A g^{-1} , with a small IR drop being observed at 10 A g^{-1} . The maximum specific capacitance value, measured at a current load of 0.05 A g^{-1} , is 23 F g^{-1} and approximately 50% of this value is maintained when increasing the current density from 0.05 to 20 A g^{-1} (Fig. 8c).

Conclusions

Bimetallic molybdenum tungsten oxynitride has been synthesised by a TPR in ammonia and extensively characterised by XRD, low-temperature N_2 adsorption, SEM and TEM. XRD and TEM analyses indicate that the synthesised material consists of a molybdenum tungsten oxynitride phase and no obvious unreacted oxide is present in the sample. It has been concluded that the material has mesoporous morphology with the maximum of the pore size distribution at around 4 nm. Mo, W, N and O elements are distributed throughout the sample. Electrochemical characteristics of MoW(N,O) in 1 M H_2SO_4 aqueous electrolyte differ from both molybdenum and tungsten monometallic oxynitrides synthesised under similar experimental conditions. The material demonstrates a capacitance of 124 F g^{-1} at a current density of 0.05 A g^{-1} in galvanostatic charge–discharge experiments. 43% of this capacitance can be retained upon the 400-fold increase in the current density from 0.05 to 20 A g^{-1} . The symmetric cell with two molybdenum tungsten oxynitride electrodes exhibits a capacitance of 23 F g^{-1} and is able to operate up to a high current of 20 A g^{-1} .

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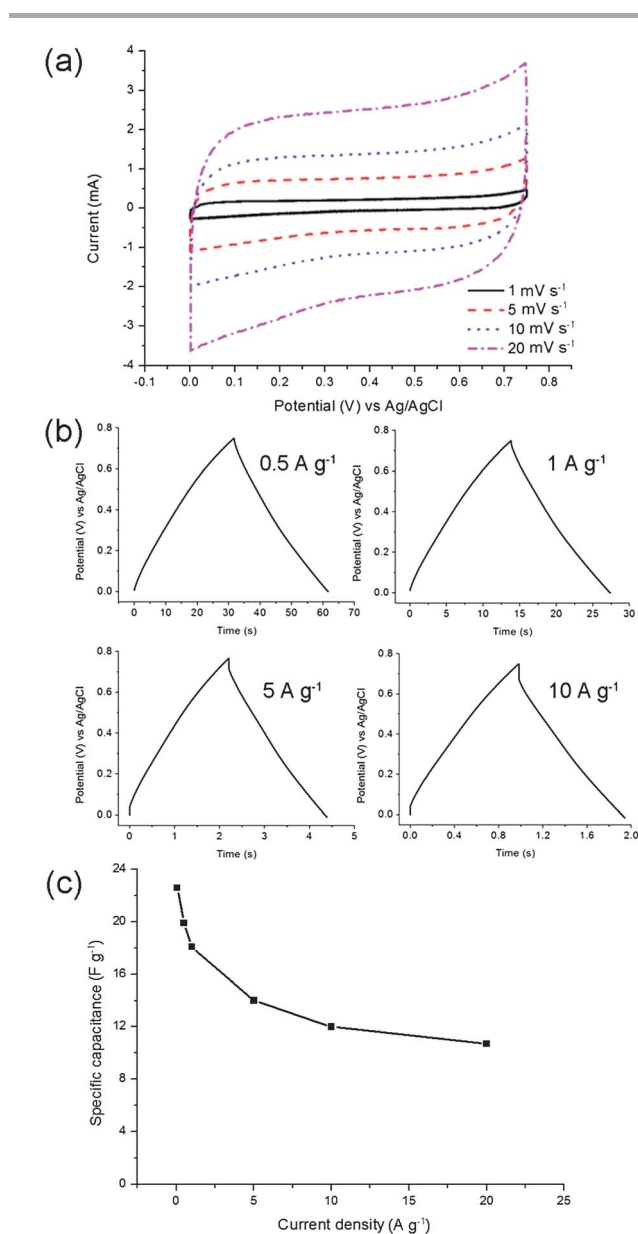


Fig. 8 Molybdenum tungsten oxynitride electrodes in a symmetric cell. Cyclic voltammetry measurements at the scan rates of 1, 5, 10 and 20 mV s^{-1} (a); galvanostatic charge and discharge curves at different current densities (b); the rate capability at the current densities between 0.05 and 20 A g^{-1} (c).



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